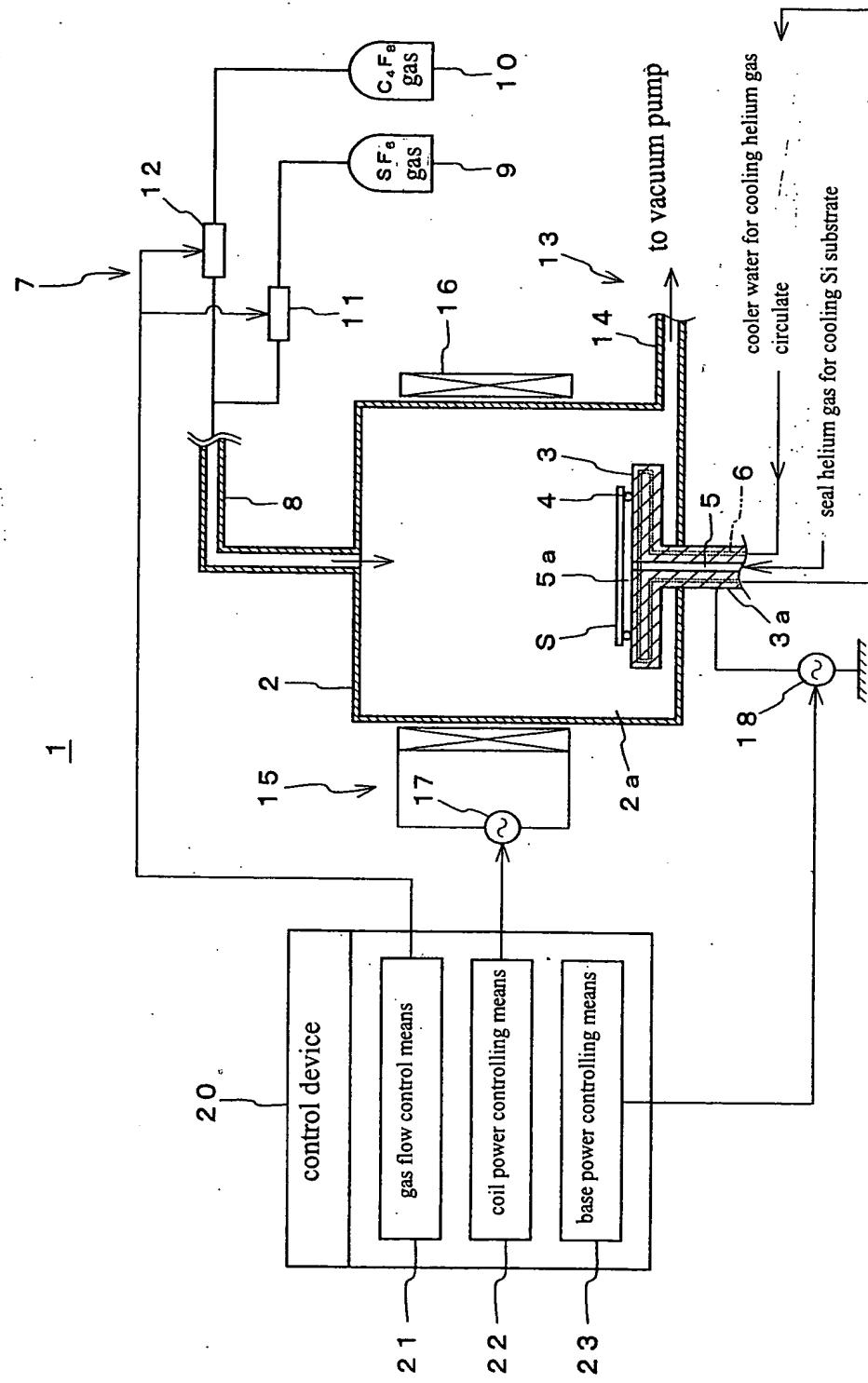


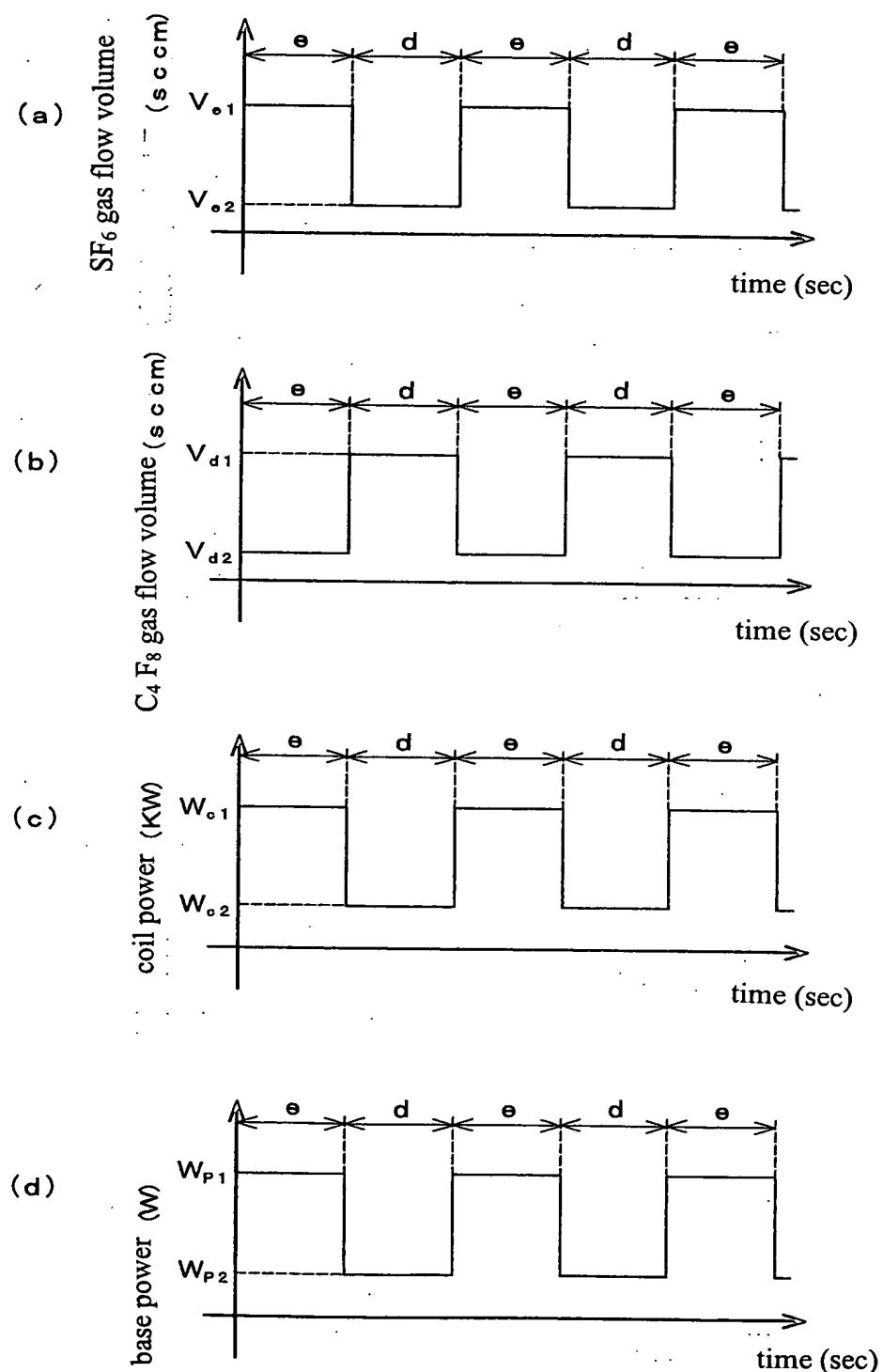
1 / 5

Fig. 1



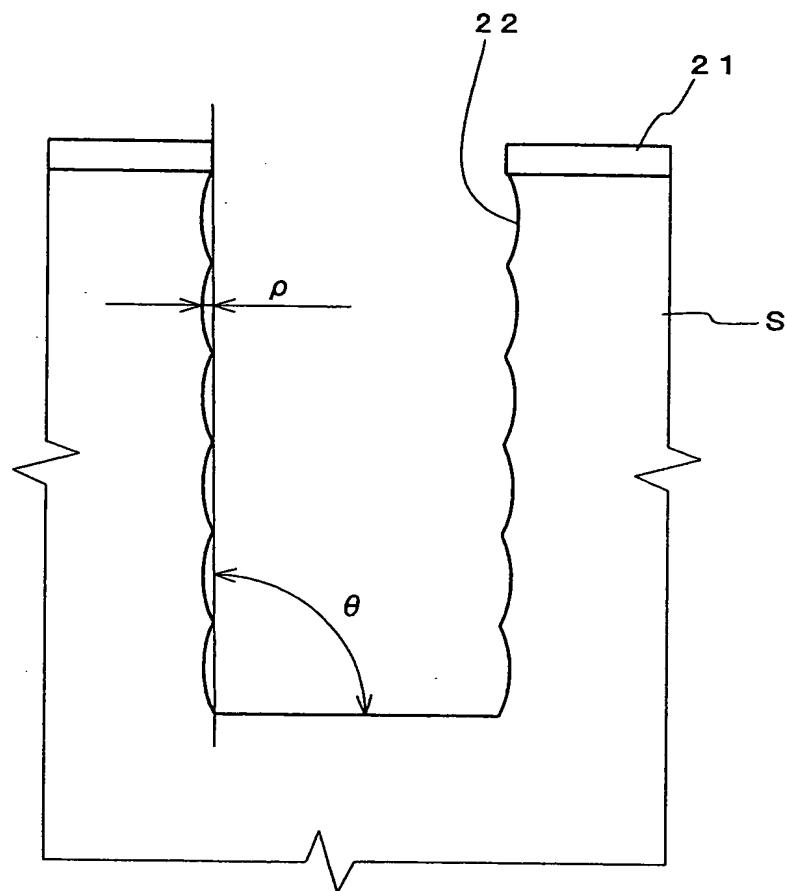
2 / 5

Fig. 2



3 / 5

Fig. 3



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Fig. 4

| | embodiment | comparative example |
|---|------------|---------------------|
| etching rate ($\mu\text{m}/\text{min}$) | 3. 7 | 3. 4 |
| mask selection ratio | 140 | 104 |
| unevenness | 160 | 250 |
| hole side wall angle | 90. 2 | 90. 5 |

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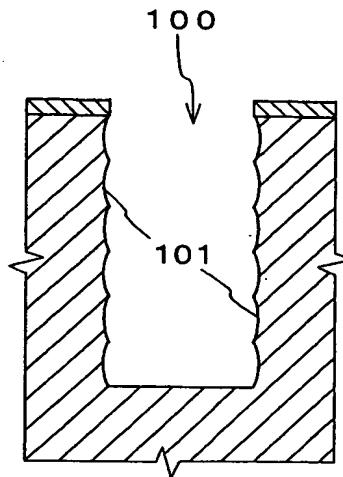


Fig. 5

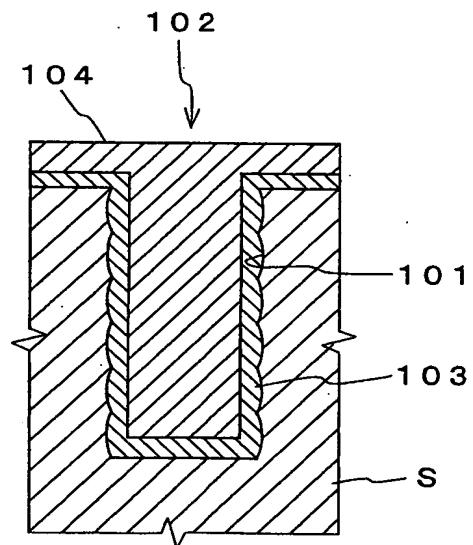


Fig. 6